

ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

Title of Invention	FET GATE STRUCTURE WITH METAL GATE ELECTRODE AND SILICIDE CONTACT													
Application Number :														
Confirmation Number:														
First Named Applicant:	Victor Ku													
Attorney Docket Number:	FIS920030124													
Art Unit:														
Examiner:														
Search string:	(6376888 or 6373111 or 5619057 or 6501131 or 6355531 or 4745079 or 20030119292 or 20020179975 or 20020086504 or 20020123189 or 20030011037 or 20030075766).pn													
US Patent Documents														
Note: Applicant is not required to submit a paper copy of cited US Patent Documents														
init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass							
	1	6376888	2002-04-23	Tsunashima et al.										
	2	6373111	2002-04-16	Zheng et al.										
	3	5619057	1997-04-08	Komatsu										
	4	6501131	2002-12-31	Divakaruni et al.										
	5	6355531	2002-03-12	Mandelman et al.										
	6	4745079	1988-05-17	Pfiester										
US Published Applications														
Note: Applicant is not required to submit a paper copy of cited US Published Applications														
init	Cite.No.	Pub. No.	Date	Applicant	Kind	Class	Subclass							
	1	20030119292	2003-06-26	Lee et al.										
	2	20020179975	2002-12-05	Wakabayashi et al.										
	3	20020086504	2002-07-04	Park et al.										
	4	20020123189	2002-09-05	Cha et al.										
	5	20030011037	2003-01-16	Chau et al.										
	6	20030075766	2003-04-24	Lin et al.										

Signature

Examiner Name	Date